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TITLE

: COSMETIC FOR SENSITIVE SKIN

ABSTRACT: PROBLEM TO BE SOLVED: To obtain a cosmetic useful for a person having sensitive

skin without anxiety by making the cosmetic include a sulfate group-containing

mucopolysaccharide and an elastase inhibitor.

SOLUTION: This cosmetic comprises (A) a sulfate group-containing mucopolysaccharide [e.g. heparin analog substance (the generic name of mucopolysaccharide such as chondroitin polysulfate), etc.], and (B) an elastase inhibitor (e.g. soybean protein). Preferably the cosmetic comprises 0.001-5 wt.% of the component A and 0.01-10 wt.% of the component B. The cosmetic useful even for a person liable to cause an excessive reactivity, a so-called person having sensitive skin without anxiety is obtained by making the cosmetic include the essential components. The cosmetic can contain an arbitrary component useful in an ordinary cosmetic such as a hydrocarbon, a higher alcohol, a polyhydric alcohol, a nonionic surfactant and an anionic surfactant besides the above-mentioned essential compounds.

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